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Sheet 3 of 5

Form PTO-1449 U.S. Department of Commerce Patent and Trademark Office		Atty. Docket No.:	Serial No.:
LIST OF PRIOR ART CITED BY APPLICANT (Use several sheets if necessary)		EP 1020-CIP	
		Applicant:	
		Sternes, et al.	
		Filing Date:	Group:

U.S. PATENT DOCUMENTS

*Examiner/Initial		Document Number	Date	Name	Class	Subclass	Filing date if appropriate
P.S.	AA	4,202,806	May 13, 1980	Yoshida et al.			
W	AB	4,284,482	April 28, 1981	Homan, Gary R.			
	AC	4,333,987	June 6, 1982	Kwart et al.			
	AD	4,338,226	July 6, 1982	Worschech et al.			
	AE	4,412,897	November 1, 1983	Kornbaum et al.			
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	AG	4,616,046	October 7, 1986	Ghonerd-Jean-Yves et al.			
W	AH	4,625,059	November 25, 1986	Shibano et al.			
P.S.	AI	4,711,920	December 1987	Kugel et al.			

Kornbaum, et al.

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		Document Number	Date	Country	Class	Subclass	Translation Yes No
P.S.	AL	JP 01090167 A	4/6/89	Japan			
P.S.	AM	JP 54-53002	April 1979	Japan			
P.S.	AN	JP 63-128002	May 1988	Japan			

OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)

P.S.	AR	The conductive sulfur/carbon mixture cathode. An efficient synthesis of thiophenes and related compounds from acetylenes. Le Guéant et al. Lab. Electrochim. Org., Univ. Cathol. Ouest, Angers 49006, Fr. Tetrahedron Letters (1986) 27 (20) 2261-2
P.S.	AS	A Novel Initiation Process for the Nonoxidative Thermal Dehydrochlorination of Poly(vinyl chloride): Apparent Intermediacy of a Cyclic Chloronium Ion by Sternes et al., Polymer Preprints (American Chemical Society, Division of Polymer Chemistry), 21 (2), pp.138-139, 1980.
P.S.	AT	Mechanistic Aspects of the Degradation and Stabilization of Poly(vinyl chloride) by W. H. Sternes, Jr., Developments in Polymer Degradation - 3; N. Grassie, Ed.; Applied Science: London, U.K., Chapter 5, pp.135-171, 1981.

EXAMINER Peter Siebel DATE CONSIDERED 3/16/85

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.